

# Masahiro Watanabe

## List of Publications by Year in descending order

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#	ARTICLE	IF	CITATIONS
1	Negative differential resistance of metal (CoSi <sub>2</sub> )/insulator (CaF <sub>2</sub> ) triple-barrier resonant tunneling diode. Applied Physics Letters, 1993, 62, 300-302.	3.3	62
2	Epitaxial Growth and Electrical Characteristics of CaF <sub>2</sub> /Si/CaF <sub>2</sub> Resonant Tunneling Diode Structures Grown on Si(111) 1°-off Substrate. Japanese Journal of Applied Physics, 2000, 39, L964-L967.	1.5	56
3	CaF <sub>2</sub> /CdF <sub>2</sub> Double-Barrier Resonant Tunneling Diode with High Room-Temperature Peak-to-Valley Ratio. Japanese Journal of Applied Physics, 2000, 39, L716-L719.	1.5	41
4	Metal(CoSi <sub>2</sub> )/Insulator(CaF <sub>2</sub> ) Resonant Tunneling Diode. Japanese Journal of Applied Physics, 1994, 33, 57-65.	1.5	38
5	Epitaxial Growth of Metal(CoSi <sub>2</sub> )/Insulator(CaF <sub>2</sub> ) Nanometer-Thick Layered Structure on Si(111). Japanese Journal of Applied Physics, 1992, 31, L116-L118.	1.5	32
6	Transistor action of metal (CoSi <sub>2</sub> )/insulator (CaF <sub>2</sub> ) hot electron transistor structure. Electronics Letters, 1992, 28, 1002-1004.	1.0	28
7	Resonant Tunneling Diodes in Si/CaF <sub>2</sub> Heterostructures Grown by Molecular Beam Epitaxy. Japanese Journal of Applied Physics, 1999, 38, L920-L922.	1.5	24
8	Negative Differential Resistance of CaF <sub>2</sub> /CdF <sub>2</sub> Triple-Barrier Resonant-Tunneling Diode on Si(111) Grown by Partially Ionized Beam Epitaxy. Japanese Journal of Applied Physics, 1999, 38, L116-L118.	1.5	23
9	Room temperature negative differential resistance of metal (CoSi <sub>2</sub> )/insulator (CaF <sub>2</sub> ) resonant tunnelling diode. Electronics Letters, 1992, 28, 1432.	1.0	22
10	Low Temperature (≈420Å°C) Epitaxial Growth of CaF <sub>2</sub> /Si(111) by Ionized-Cluster-Beam Technique. Japanese Journal of Applied Physics, 1990, 29, 1803-1804.	1.5	16
11	Epitaxial Growth and Ultraviolet Photoluminescence of CaF <sub>2</sub> /ZnO/CaF <sub>2</sub> Heterostructures on Si(111). Japanese Journal of Applied Physics, 2000, 39, L500-L502.	1.5	15
12	BeMgZnSe-based ultraviolet lasers. Semiconductor Science and Technology, 2005, 20, 1187-1197.	2.0	15
13	Detection of hot electron current with scanning hot electron microscopy. Applied Physics Letters, 1996, 69, 2196-2198.	3.3	14
14	Suppression of Leakage Current of CdF <sub>2</sub> /CaF <sub>2</sub> Resonant Tunneling Diode Structures Grown on Si(100) Substrates by Nanoarea Local Epitaxy. Japanese Journal of Applied Physics, 2007, 46, 3388-3390.	1.5	13
15	Resistance switching memory characteristics of Si/CaF <sub>2</sub> /CdF <sub>2</sub> /CaF <sub>2</sub> /Si resonant-tunneling quantum-well structures. Applied Physics Express, 2014, 7, 044103.	2.4	13
16	Theoretical and measured characteristics of metal (CoSi <sub>2</sub> )/insulator(CaF <sub>2</sub> ) resonant tunneling transistors and the influence of parasitic elements. IEEE Transactions on Electron Devices, 1995, 42, 2203-2210.	3.0	12
17	Proposal and Analysis of Very Short Channel Field Effect Transistor Using Vertical Tunneling with New Heterostructures on Silicon. Japanese Journal of Applied Physics, 1996, 35, L1104-L1106.	1.5	12
18	Epitaxial growth of nanometer-thick CaF <sub>2</sub> /CdF <sub>2</sub> heterostructures using partially ionized beam epitaxy. Solid-State Electronics, 1998, 42, 1627-1630.	1.4	12

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19	Epitaxial growth and electrical conductance of metal(CoSi <sub>2</sub> )/insulator(CaF <sub>2</sub> ) nanometer-thick layered structures on Si (111). Journal of Electronic Materials, 1992, 21, 783-789.	2.2	11
20	Room temperature negative differential resistance of CdF <sub>2</sub> •CaF <sub>2</sub> double-barrier resonant tunneling diode structures grown on Si(100) substrates. Applied Physics Letters, 2007, 90, 092101.	3.3	11
21	Quantum Interference of Electron Wave in Metal $(\text{CoSi}_{2})/\text{Insulator}(\text{CaF}_{2})$ Resonant Tunneling Hot Electron Transistor Structure. Japanese Journal of Applied Physics, 1994, 33, L1762-L1765.	1.5	10
22	Resistance Switching Memory Characteristics of Si/CaF <sub>2</sub> <sub>2</sub> /CdF <sub>2</sub> Quantum-Well Structures Grown on Metal (CoSi <sub>2</sub> ) Layer. Japanese Journal of Applied Physics, 2013, 52, 04CJ07.	1.5	10
23	Visible Electroluminescence from Nanocrystalline Silicon Embedded in Single-Crystalline CaF <sub>2</sub> /Si(111) with Rapid Thermal Anneal. Japanese Journal of Applied Physics, 1999, 38, L904-L906.	1.5	9
24	Room-Temperature Electroluminescence from Single-Period (CdF <sub>2</sub> /CaF <sub>2</sub> ) Inter-Subband Quantum Cascade Structure on Si substrate. Japanese Journal of Applied Physics, 2006, 45, 3656-3658.	1.5	9
25	Resistance switching memory characteristics of CaF <sub>2</sub> /Si/CaF <sub>2</sub> resonant-tunneling quantum-well heterostructures sandwiched by nanocrystalline Si secondary barrier layers. Applied Physics Express, 2016, 9, 074001.	2.4	9
26	Improvement of the Visible Electroluminescence from Nanocrystalline Silicon Embedded in CaF <sub>2</sub> on Si(111) Substrate Prepared by Rapid Thermal Annealing. Japanese Journal of Applied Physics, 2000, 39, 1996-2000.	1.5	8
27	Metal (CoSi <sub>2</sub> )/Insulator (CaF <sub>2</sub> ) Hot Electron Transistor Fabricated by Electron-Beam Lithography on a Si Substrate. Japanese Journal of Applied Physics, 1995, 34, L1254-L1256.	1.5	7
28	Electroluminescence of Nanocrystal Si Embedded in Single-Crystal CaF <sub>2</sub> /Si(111). Japanese Journal of Applied Physics, 1998, 37, L591-L593.	1.5	7
29	Shortening of Detection Time for Observation of Hot Electron Spatial Distribution by Scanning Hot Electron Microscopy. Japanese Journal of Applied Physics, 1999, 38, 2108-2113.	1.5	7
30	Theoretical Analysis of The threshold Current Density in BeMgZnSe Quantum-Well Ultraviolet Lasers. Japanese Journal of Applied Physics, 2001, 40, 6872-6873.	1.5	7
31	Epitaxial growth of a metal(CoSi <sub>2</sub> )/insulator(CaF <sub>2</sub> ) nanometer-thick heterostructure and its application to quantum-effect devices. Journal of Vacuum Science and Technology A: Vacuum, Surfaces and Films, 1995, 13, 623-628.	2.1	6
32	Epitaxial Growth of BeZnSe on CaF <sub>2</sub> /Si(111) Substrate. Japanese Journal of Applied Physics, 2002, 41, L876-L877.	1.5	6
33	Formation of Silicon and Cobalt Silicide Nanoparticles in CaF <sub>2</sub> . Japanese Journal of Applied Physics, 1995, 34, 4380-4383.	1.5	5
34	Multiple Negative Differential Resistance due to Quantum Interference of Hot Electron Waves in Metal (CoSi <sub>2</sub> )/Insulator (CaF <sub>2</sub> ) Heterostructures and Influence of Parasitic Circuit Elements. Japanese Journal of Applied Physics, 1995, 34, 4481-4484.	1.5	5
35	Room-temperature observation of multiple negative differential resistance in a metal (CoSi <sub>2</sub> )/insulator (CaF <sub>2</sub> ) quantum interference transistor structure. Physica B: Condensed Matter, 1996, 227, 213-215.	2.7	5
36	Room-Temperature Ultraviolet Photoluminescence of BeZnSe on GaP(001). Japanese Journal of Applied Physics, 2002, 41, L751-L753.	1.5	5

#	ARTICLE	IF	CITATIONS
37	Analysis of single- and double-barrier tunneling diode structures using ultrathin CaF <sub>2</sub> /CdF <sub>2</sub> /Si multilayered heterostructures grown on Si. Japanese Journal of Applied Physics, 2015, 54, 04DJ05.	1.5	5
38	Improvement of Crystalline Quality of BeZnSe Using Buffer Layer by Migration Enhanced Epitaxy on GaP(001) Substrate. Japanese Journal of Applied Physics, 2005, 44, L75-L77.	1.5	4
39	Room temperature near-infrared electroluminescence of Si/CaF <sub>2</sub> quantum cascade laser structures grown on an SOI substrate. Japanese Journal of Applied Physics, 2021, 60, SBBE03.	1.5	4
40	Reflection High-Energy Electron Diffraction Oscillation during CaF <sub>2</sub> Growth on Si(111) by Partially Ionized Beam Epitaxy. Japanese Journal of Applied Physics, 1993, 32, 940-941.	1.5	3
41	Seventy-nm-Pitch Patterning on CaF <sub>2</sub> by e-beam Exposure. Japanese Journal of Applied Physics, 1996, 35, 6342-6343.	1.5	3
42	Effect of Buffer Layer on Epitaxial Growth of High-Magnesium-Content BeMgZnSe Lattice Matched to GaP(001) Substrate. Japanese Journal of Applied Physics, 2003, 42, L599-L602.	1.5	3
43	Light emission from Si nanocrystals embedded in CaF <sub>2</sub> epilayers on Si(111): Effect of rapid thermal annealing. Journal of Luminescence, 1998, 80, 253-256.	3.1	2
44	Negative differential resistance of CaF <sub>2</sub> /Si double barrier resonant tunneling diodes fabricated using plasma etching mesa isolation process. Japanese Journal of Applied Physics, 2020, 59, SIIE03.	1.5	2
45	Design, fabrication, and evaluation of waveguide structure using Si/CaF <sub>2</sub> heterostructure for near- and mid- infrared silicon photonics. IEICE Transactions on Electronics, 2022, , .	0.6	2
46	Reduction of Electrical Resistance of Nanometer-Thick CoSi <sub>2</sub> Film on CaF <sub>2</sub> by Pseudomorphic Growth of CaF <sub>2</sub> on Si(111). Japanese Journal of Applied Physics, 1997, 36, 4470-4471.	1.5	1
47	Epitaxial growth and optical properties for ultraviolet regionof BeMgZnSe on GaP(001) substrate. Physica Status Solidi (B): Basic Research, 2004, 241, 479-482.	1.5	1
48	Improvement of electroluminescence from CdF <sub>2</sub> /CaF <sub>2</sub> intersubband transition light-emitting structure by trench patterning and hydrogen annealing of Si substrate. IEICE Electronics Express, 2006, 3, 493-498.	0.8	1
49	Optically pumped ultraviolet lasing of BeMgZnSe based quantum well laser structures. Physica Status Solidi C: Current Topics in Solid State Physics, 2006, 3, 878-880.	0.8	1
50	Negative differential resistance in metal (CoSi <sub>2</sub> /insulator (CaF <sub>2</sub> ) resonant tunneling diode. IEEE Transactions on Electron Devices, 1992, 39, 2644.	3.0	0
51	Transfer efficiency of hot electrons in a metal(CoSi <sub>2</sub> )/insulator(CaF <sub>2</sub> ) quantum interference transistor. Surface Science, 1996, 361-362, 209-212.	1.9	0
52	Room temperature negative differential resistance with high peak-to-valley current ratio of CdF <sub>2</sub> /CaF <sub>2</sub> resonant tunneling diode on silicon. , 0, , .		0
53	Ultraviolet lasing from optically pumped BeMgZnSe quantum-well laser structures. Applied Physics Letters, 2005, 87, 142106.	3.3	0